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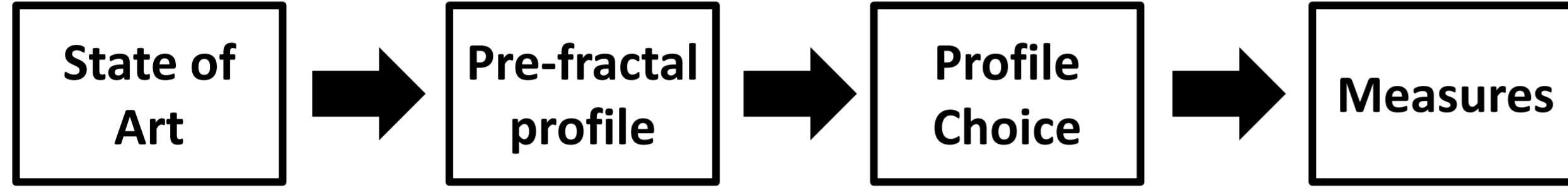
## Introduction

Energy harvesting  
Wireless Power Transmission } → Antennas need to receive energy over wideband

Use of UWB antennas required

Issue: Antenna sizes for low frequency applications

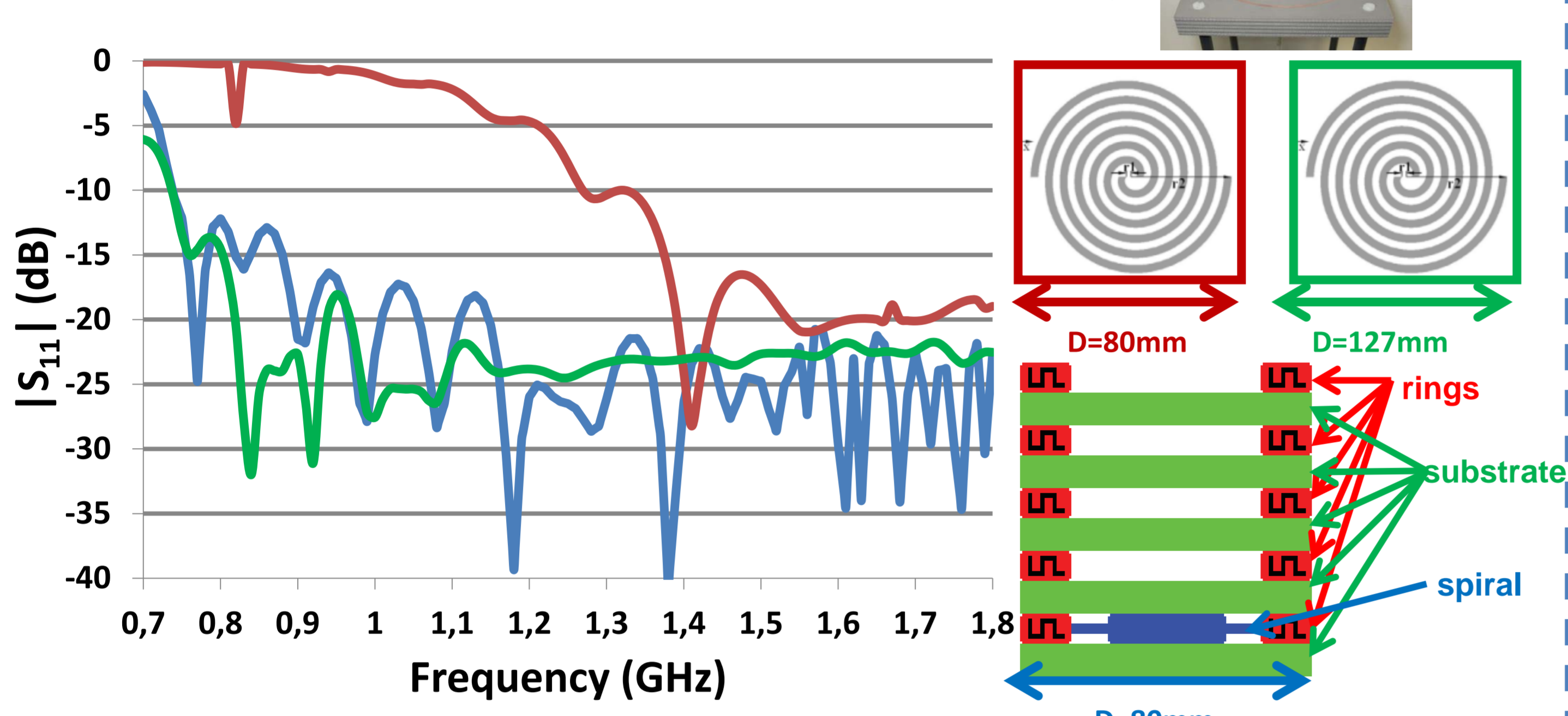
Objective: Miniaturized UWB antennas



## State of Art

An innovative architecture for miniaturization of UWB antenna is reported in [1]:

Antenna with stacked crenelated metallic rings



Principal:

Lowest operating frequency of such an antenna depending on:

- Number of stacked metallic rings
- Unfolded length  $L$  of the ring's contour (or  $f_{res}$ )
- Position of different rings above the spiral

😊 37% reduction of the antenna  
No degradation of the radiating performances

😡 ↑ antenna thickness (height= $N/25$ )  
Limitation in  $f_{res}$  & miniaturization with crenel profile  
Time-consuming EM simulation (difficult optimization)

[1] O. Ripoche, H. Aubert, A. Bellion, P. Pouliguen, P. Potier, "Spiral antenna miniaturization in very high frequency band", Antenna Technology and Applied Electromagnetics (Antem), 25-28 juin 2012

## Pre-fractal profiles

Iteration Order	Von-Koch	Hilbert-Inspired (HI)	Peano-Inspired (PI)
1			
2			
3			

😊 New degree of freedom : iteration order

😊 New degree of freedom : the sine amplitude

😡 A high number of points required for a good definition

Modified Von Koch (MVK) [2]

[2] H. Diez, H. Aubert, D. Bellot, A. Takacs, "Antenne hélice compacte à profil sinusoïdal modulant un motif fractal", french patent pending CNES-CNRS n°04576-01/20.

## Conclusions

- Characterization of new profiles
- Comparison of their resonant frequency and quality factor to the crenel
- Definition of criteria to choose the most suitable profile depending on the application

## Choice of Profile

The choice of the most suitable profile in a given application is the results of a trade-off between two criteria

Primary criteria

For a given  $L$ , a compromise needs to be made between:

lowest  $Q$

lowest  $f_{res}$

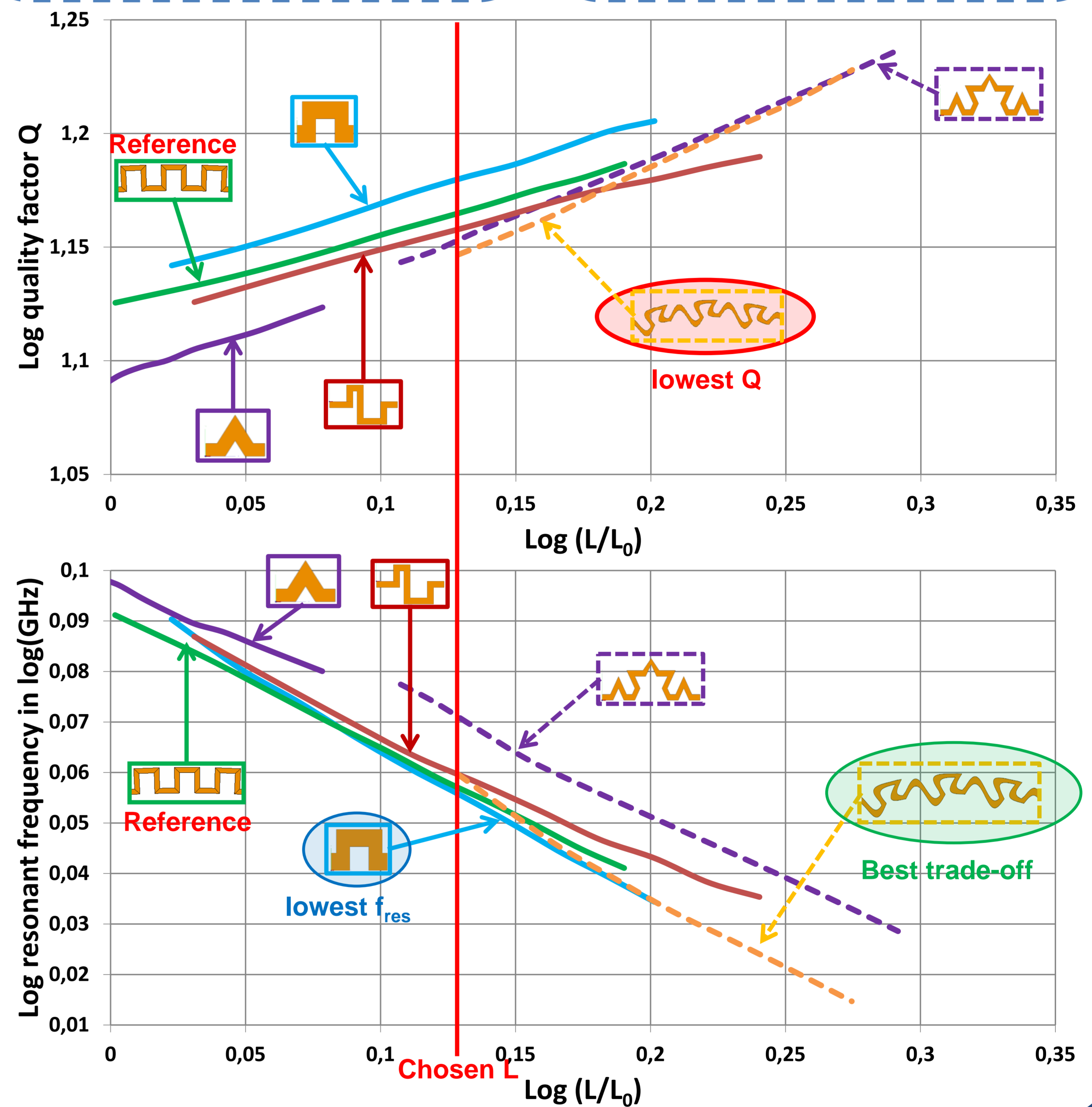
Two antagonist parameters

Application criteria

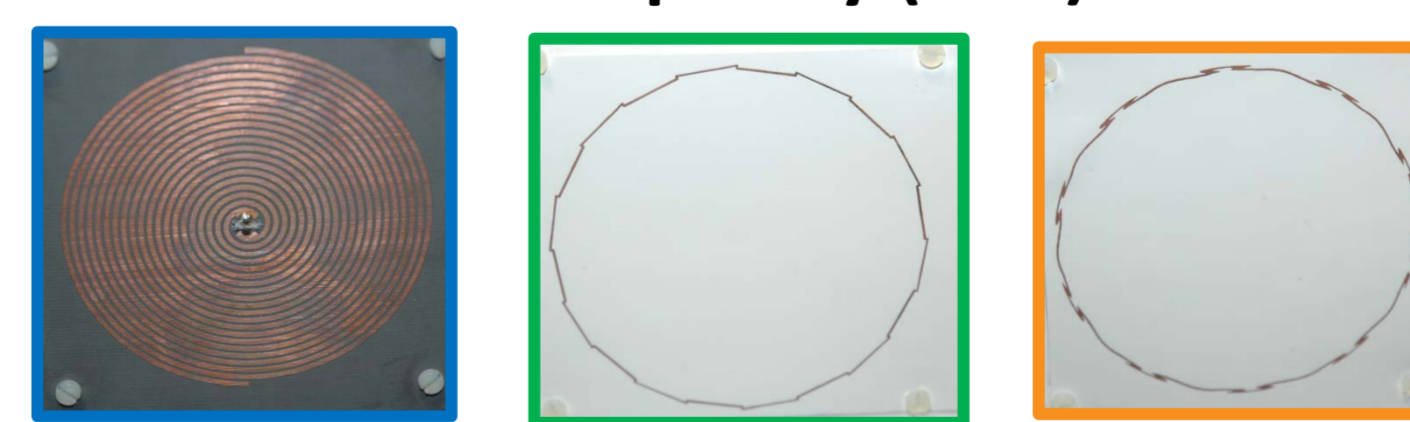
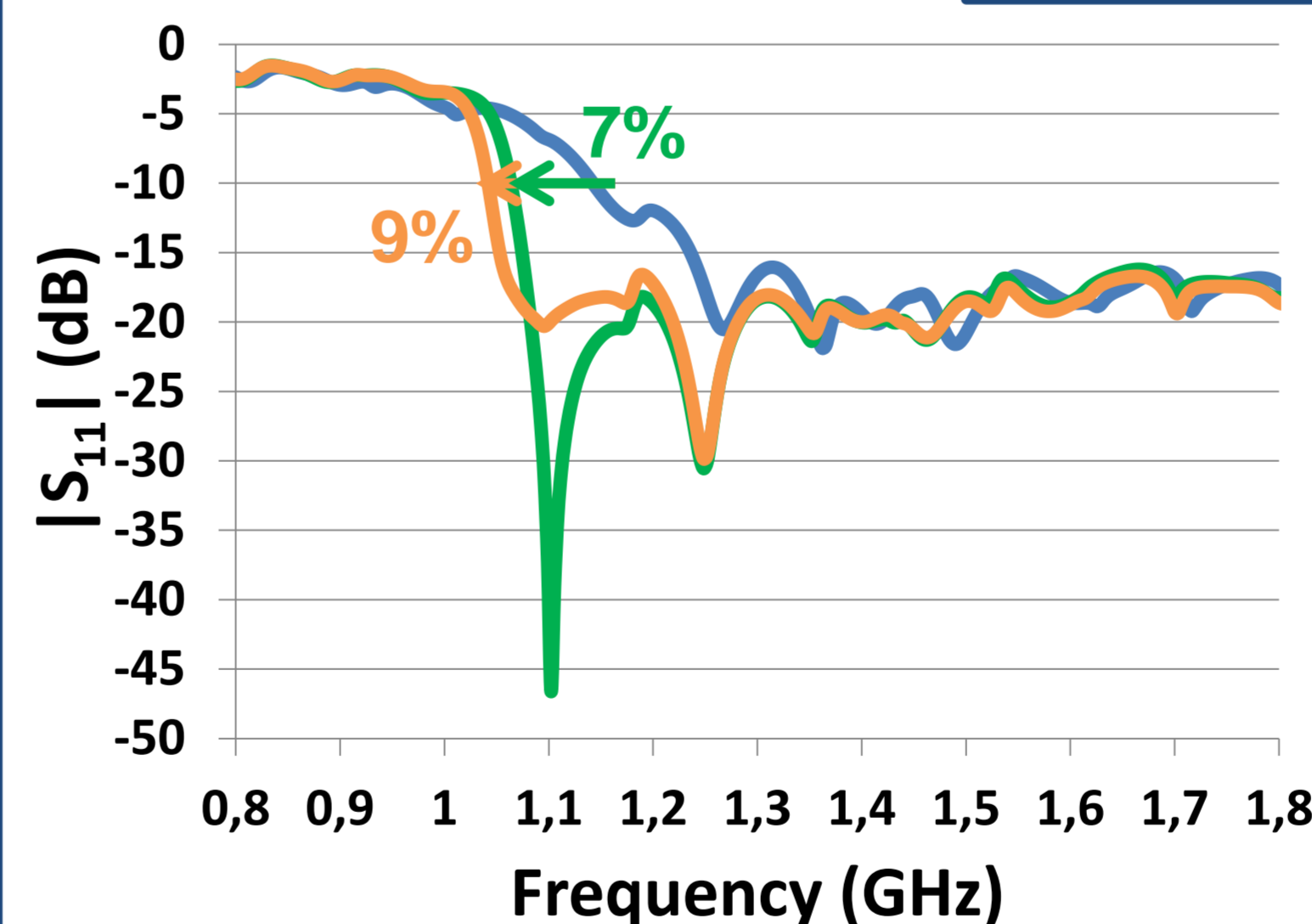
In a given application, a profile needs to be realizable and limit the computation time. We will choose a profile with :

lowest fractal iteration

lowest number of replicas



## Measures



😊 9% diminution of the lowest operating frequency with the MVK profile without deteriorating the radiating performances

Gain (dBi)	$\phi=0^\circ$	$\phi=90^\circ$
Lowest frequency		
1,8 GHz		
3 GHz		
5 GHz		